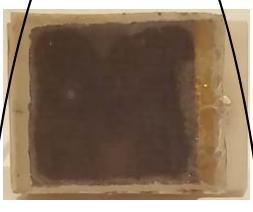
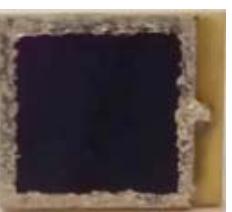
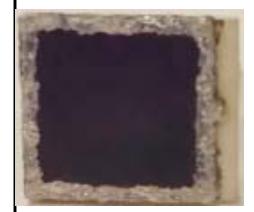
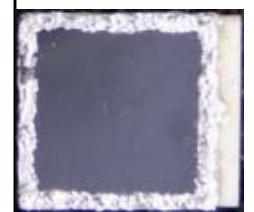
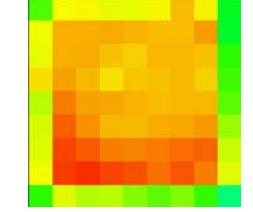
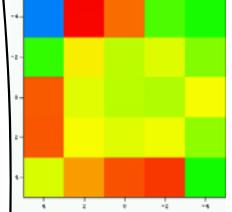
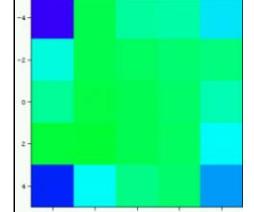
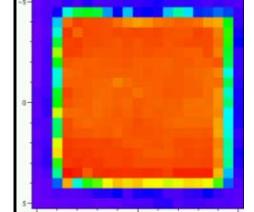
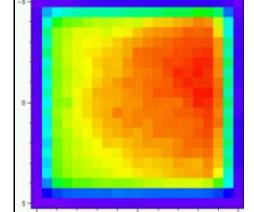
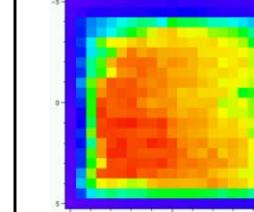
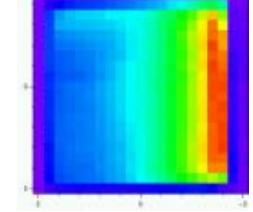
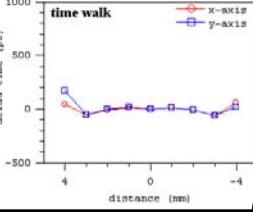
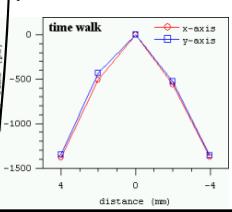
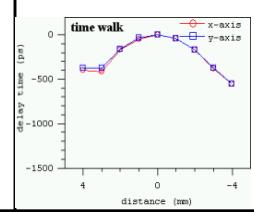
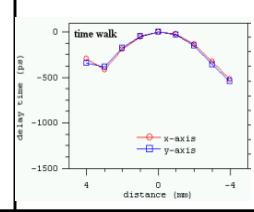
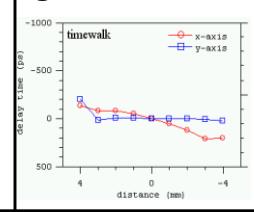
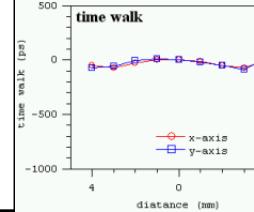
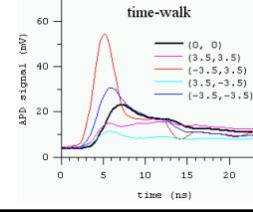
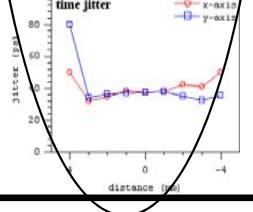
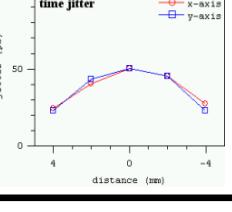
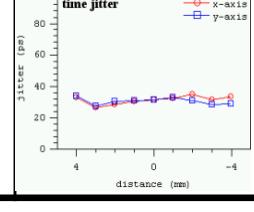
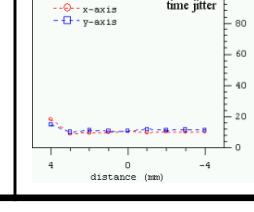
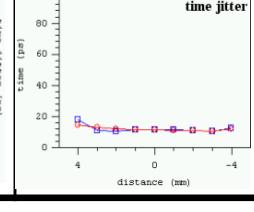
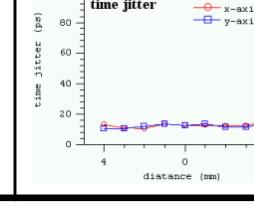
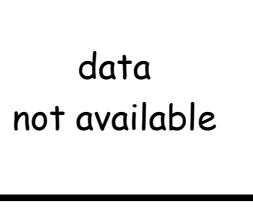


# Summary of RMD 8x8 mm<sup>2</sup> APDs

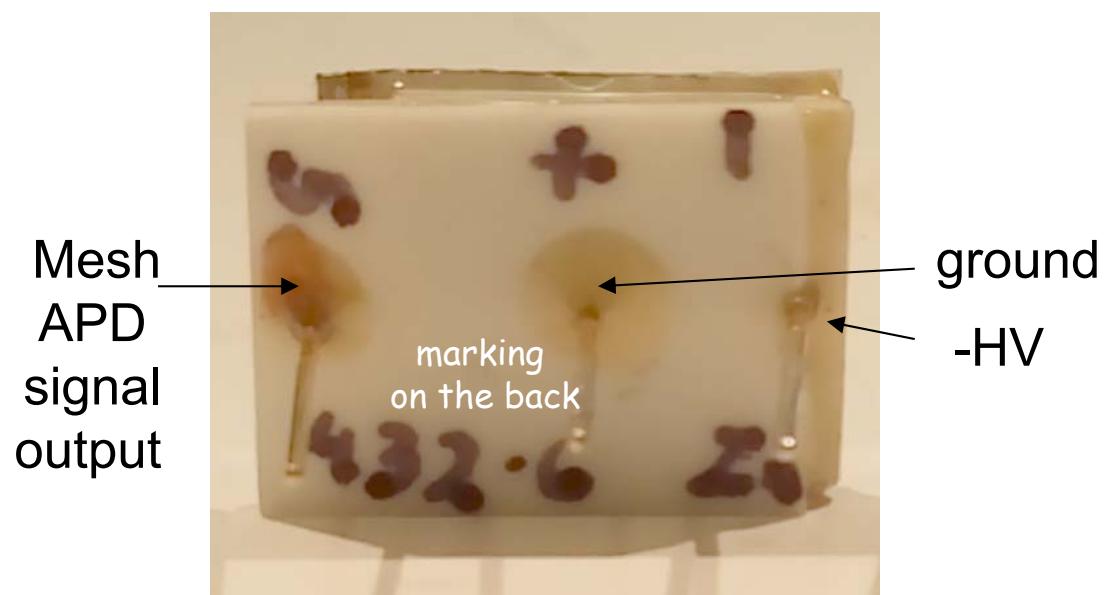
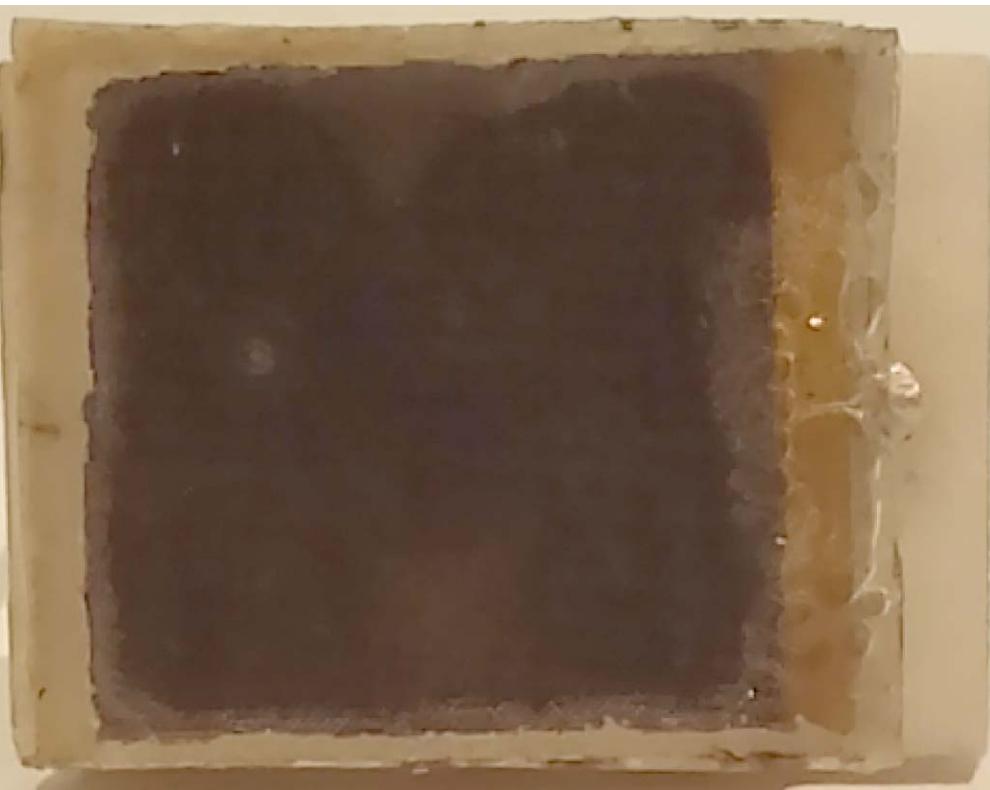
T. Tsang, BNL, Dec. 13, 2013

Dec. 13, 2013 432-6 Mesh	Nov.14, 2013 4 (previously graphene)	Nov.14, 2013 432-6-In	Oct.22, 2012 193A-6-In	Oct.22, 2012 420-3-4	Nov. 20, 2012 432-5	Sept. 26, 2012 unknown
Al-mesh Au sintered	In-edged No Au	In-edged Au sintered	In-edged Au sintered	Al-coated No Au	Al-mesh No Au	standard n+ diffusion No Au
						
good	fair	fair	good	poor	poor-fair	poor
						
good	poor	fair	fair	good	good	poor
						
good	poor	good	good	good	good	poor
						 data not available

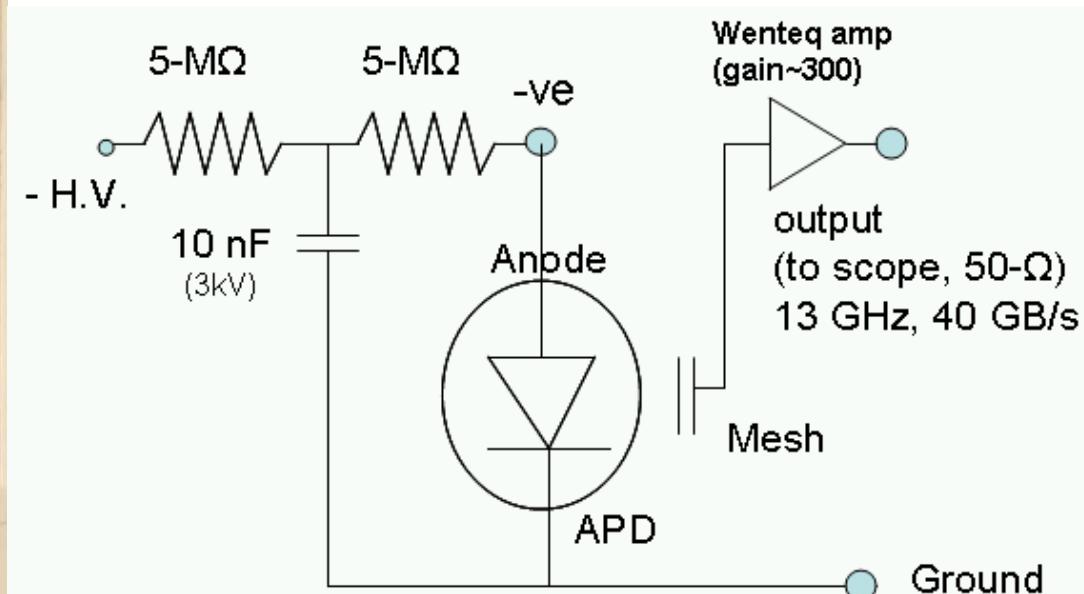
**Conclusion: metallic mesh with gold sintered device is the best of all.**

We need only a simple parallel plate capacitor geometry to maintain the field lines throughout the entire ADP surface

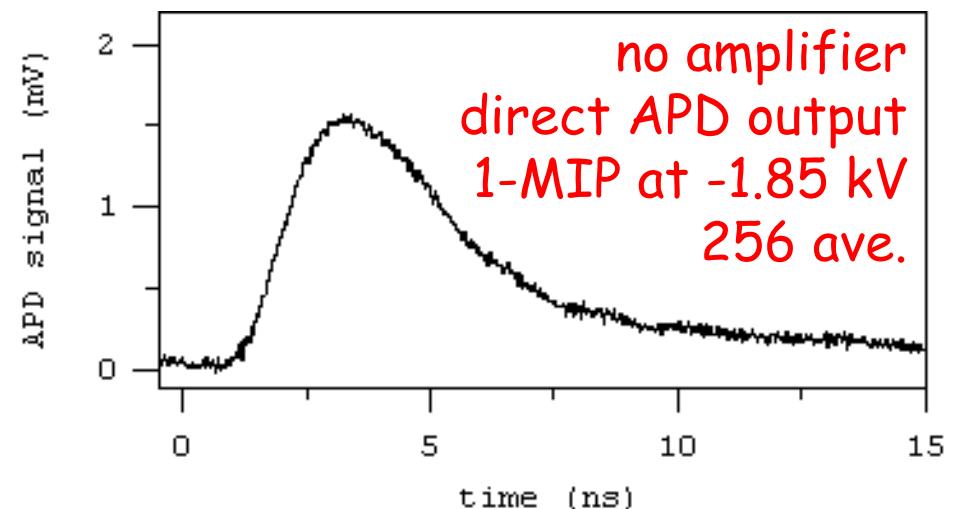
Dec. 13, 2013 APD 8x8 mm<sup>2</sup>  
Al-mesh, Au sintered, s/n 432-6



APD bias at **-1.85 kV**  
980 nm Vcsel, ~1 ns pulse, 1 kHz  
**~1 MIP equivalent photons on APD**  
(accounted for the transmission of mesh + etc ~50%)



Circuit diagram

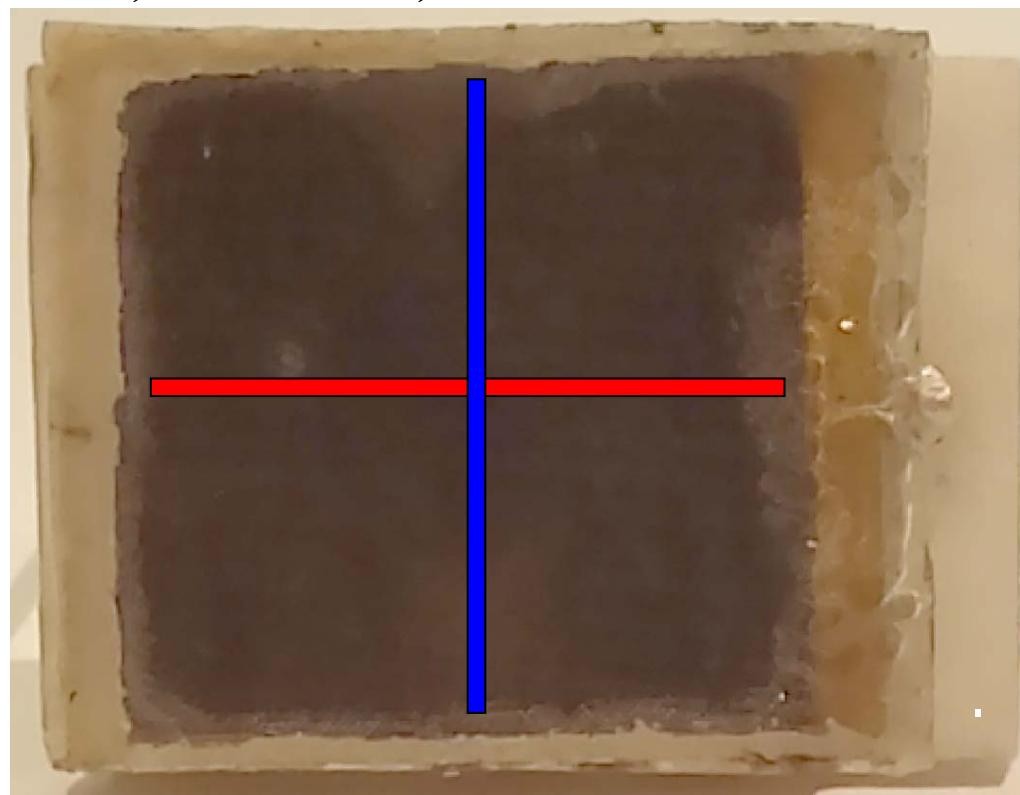


Dec. 13, 2013 APD 8x8 mm<sup>2</sup>

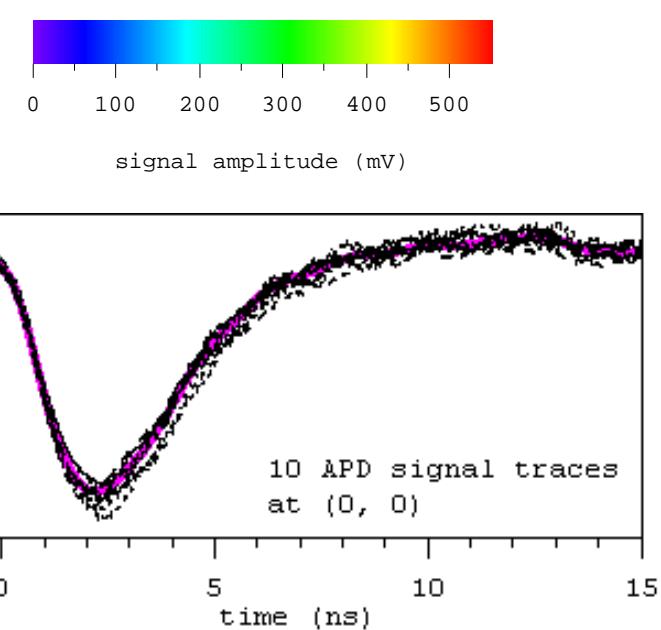
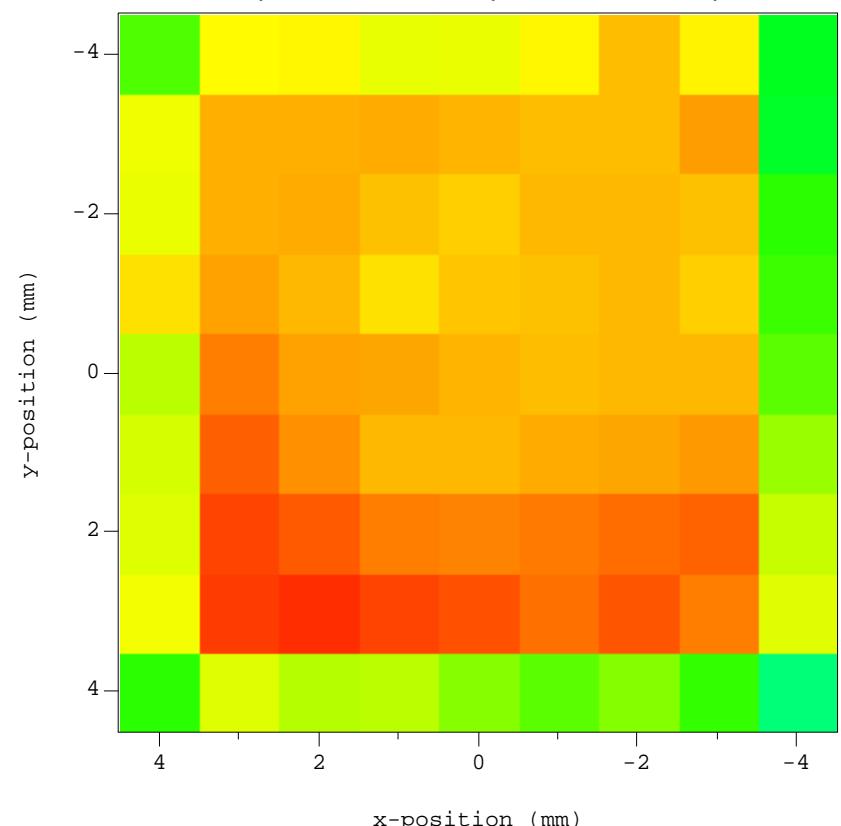
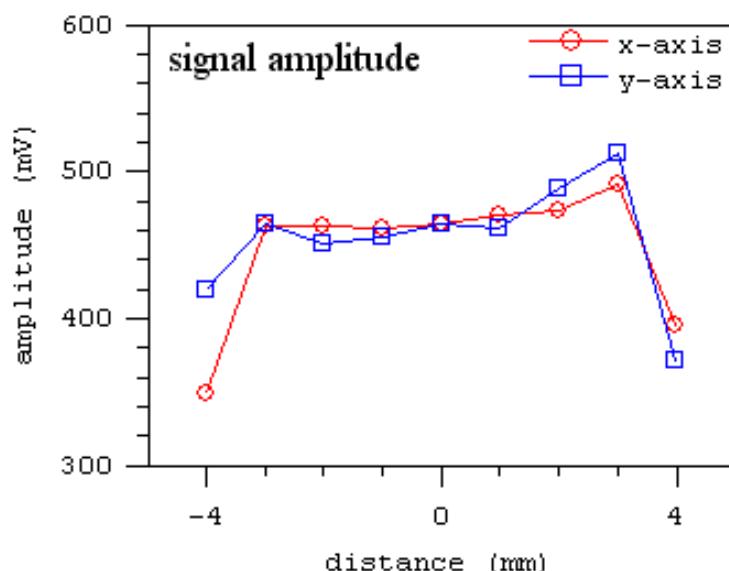
-1.85 kV ~1 MIP

spatial response map

Al-mesh, Au sintered, s/n 432-6



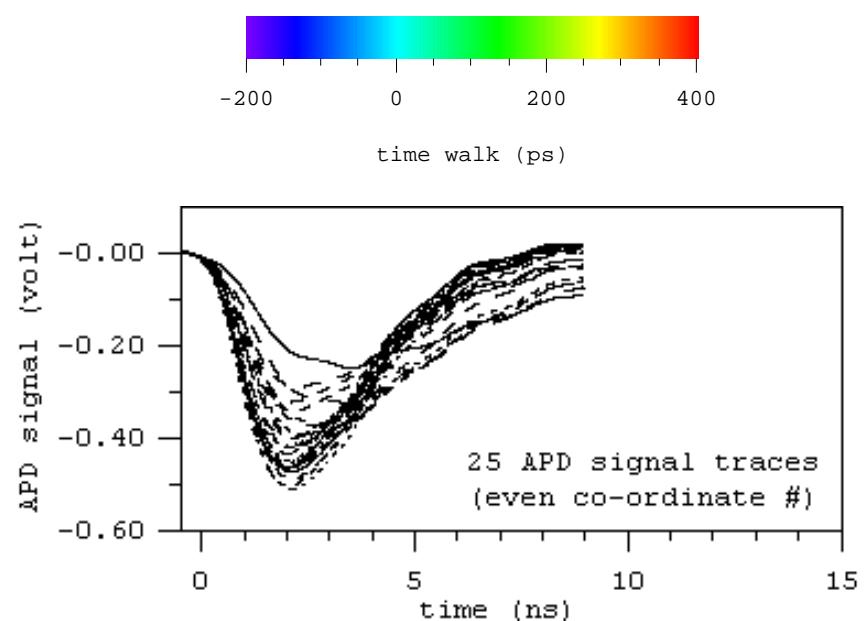
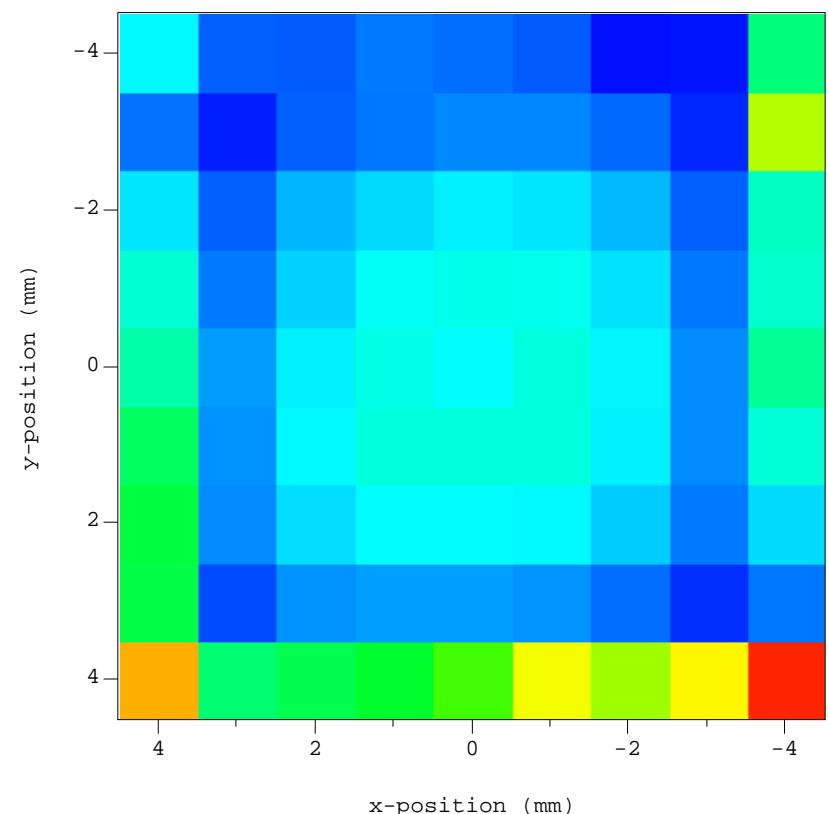
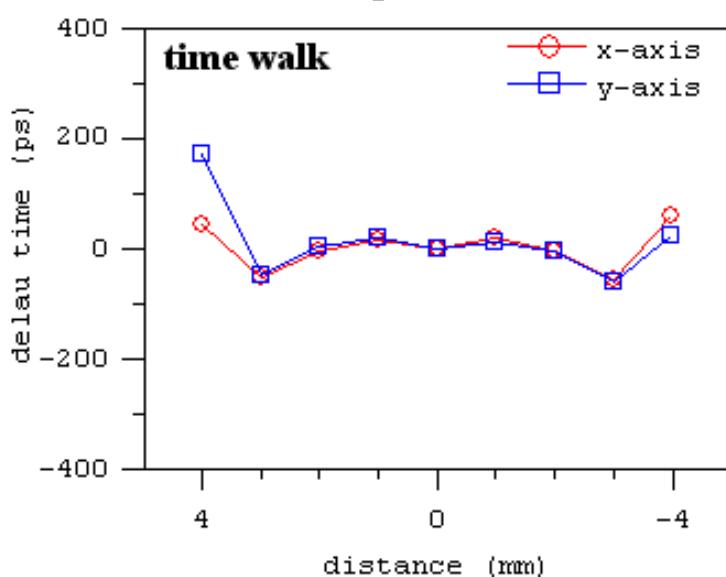
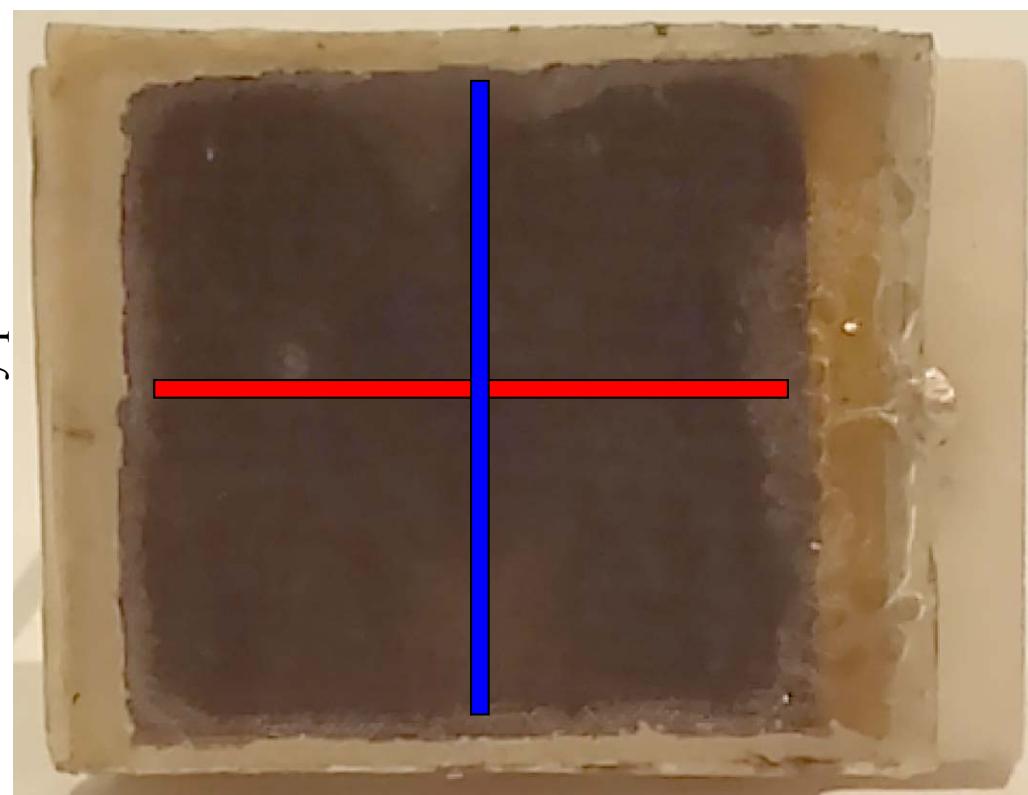
← + x-position



Dec. 13, 2013 APD 8x8 mm<sup>2</sup>  
Al-mesh, Au sintered, s/n 432-6

-1.85 kV ~1 MIP

time walk map



Dec. 13, 2013 APD 8x8 mm<sup>2</sup>  
Al-mesh, Au sintered, s/n 432-6

-1.85 kV ~1 MIP

time jitter map

